A	Application No.	Applicant(s)	
Nouce of Allowability	0/091,485	MITTELSTADT ET	Δ1 .
	xaminer	Art Unit	T.
	Dah-Wei D. Yuan	1745	
The MAILING DATE of this communication appears All claims being allowable, PROSECUTION ON THE MERITS IS (OI herewith (or previously mailed), a Notice of Allowance (PTOL-85) or NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGH of the Office or upon petition by the applicant. See 37 CFR 1.313 an	other appropriate communication This application is subject to	lication. If not includ	ed
1. This communication is responsive to <u>9/28/04</u> .			,
2. The allowed claim(s) is/are <u>1-10,47,48 and 50</u> .			
3. The drawings filed on <u>07 March 2002</u> are accepted by the Exa	aminer.		
 4. ☐ Acknowledgment is made of a claim for foreign priority under a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have been considered as a claim for foreign priority under 	en received.		
Certified copies of the priority documents have be	en received in Application No.	·	
 Copies of the certified copies of the priority docum 	nents have been received in this n	ational stage applica	tion from the
International Bureau (PCT Rule 17.2(a)).			
* Certified copies not received:	•		
Applicant has THREE MONTHS FROM THE "MAILING DATE" of the noted below. Failure to timely comply will result in ABANDONMENTHIS THREE-MONTH PERIOD IS NOT EXTENDABLE.	nis communication to file a reply of T of this application.	omplying with the rec	uirements
5. A SUBSTITUTE OATH OR DECLARATION must be submitted INFORMAL PATENT APPLICATION (PTO-152) which gives re	I. Note the attached EXAMINER'S eason(s) why the oath or declaration	AMENDMENT or No	OTICE OF
6. CORRECTED DRAWINGS (as "replacement sheets") must be	submitted.		
(a) ☐ including changes required by the Notice of Draftsperson's	Patent Drawing Review (PTO-94	18) attached	
1) ☐ hereto or 2) ☐ to Paper No./Mail Date			
(b) \(\sum_\) including changes required by the attached Examiner's Am Paper No./Mail Date			
Identifying indicia such as the application number (see 37 CFR 1.84(c each sheet. Replacement sheet(s) should be labeled as such in the he)) should be written on the drawing eader according to 37 CFR 1.121(d).	s in the front (not the	back) of
 DEPOSIT OF and/or INFORMATION about the deposit of attached Examiner's comment regarding REQUIREMENT FOR 	FRIOLOGICAL MATERIAL		ote the
Attachment(s)			
1. Notice of References Cited (PTO-892)	5 Notice of Informal D-4	ont Annlined: (D=0	450
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	5. ☐ Notice of Informal Pate6. ☐ Interview Summary (P		·152)
3. ☐ Information Disclosure Statements (PTO-1449 or PTO/SB/08)	Paper No./Mail Date 7. Examiner's Amendmen		÷
Paper No./Mail Date 1. Examiner's Comment Regarding Requirement for Deposit	8. Examiner's Statement		
of Biological Material	9. ☐ Other	OF NEASONS FOR AllOW	ance

Application/Control Number: 10/091,485

Art Unit: 1745

ION EXCHANGE SYSTEM STRUCTURE WITH A MICROTEXTURED SURFACE, METHOD OF MANUFACTURE, AND METHOD OF USE THEREOF

Examiner: Yuan

S.N. 10/091,485

Art Unit: 1745

November 18, 2004

Continued Examination Under 37 CFR 1.114

- 1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on August 24, 2004 has been entered. Claims 11-19,49 were cancelled. Claims 1,50 were amended.
- 2. The text of those sections of Title 35, U.S.C. code not included in this action can be found in the prior Office Action issued on May 28, 2004.

Claim Rejections

3. The claim rejections under 35 U.S.C. 102(e) as anticipated by Ruhl et al. on claims 1-10,47-50 are withdrawn because the independent claim 1 has been amended. The claim rejections under 35 U.S.C. 102(e) as anticipated by Shastri et al. on claims 1-3,8,9,47-50 are withdrawn because the independent claim 1 has been amended.

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Reasons for Allowance

4. Claims 1-10,47,48,50 are allowed. The invention of independent claim 1 recites a substrate for an ion-exchange electrode structure comprising an exterior surface wherein at least a potion of the exterior surface is irradiated by a laser radiation, wherein the reactive surface area has two-scales of roughness, a first scale of roughness at least three orders of magnitude different than a second scale of roughness. The closest prior arts of record, Ruhl et al. and Shastri et al., do not teach or suggest aforementioned features on the exterior surface of the substrate for an ion-exchange electrode structure. In addition, the references do not disclose any special laser ablation technique that would result Iin the two-scale roughness as recited in the claim.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dah-Wei D. Yuan whose telephone number is (571) 272-1295. The examiner can normally be reached on Monday-Friday (8:00-5:00).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Patrick J. Ryan, can be reached on (571) 272-1292. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you

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have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Dah-Wei D. Yuan November 18, 2004 Delive: /